



**PATENT APPLICATION**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of

Docket No: Q64664

Kiyoshi KAMITANI

Appln. No.: 09/895,264

Confirmation No.: 7751

Filed: July 2, 2001

For: METHOD OF MANUFACTURING LITHOGRAPHIC PRINTING PLATE

**AMENDMENT UNDER 37 C.F.R. § 1.111**

Commissioner for Patents  
Washington, D.C. 20231

Sir:

In response to the Office Action dated May 16, 2002, please amend the above-identified application as follows:

**IN THE CLAIMS:**

**Please cancel claims 4, 7, 8, 10, 11, 15, and 16 without prejudice or disclaimer.**

**Please enter the following amended claims:**

1. (Amended) A method for manufacturing a lithographic printing plate, the method comprising:  
conveying a support, on which a photosensitive coating solution containing an organic solvent is coated such that a photosensitive coated layer is formed by the photosensitive coating solution;  
drying the photosensitive coated layer by a first heating means to a dry-to-touch state;

**RECEIVED**  
NOV 07 2002  
**TC 1700**

Group Art Unit: 1762

Examiner: Rebecca A. BLANTON

#7/a  
Ingle  
11/7/02

*[Handwritten signature]*  
*[Handwritten signature]*